

# ELECTROCHEMISTRY LABORATORY

# Surface investigation of 30nm amorphous Si thin films cycled as negative electrode for Li-ion batteries G. Ferraresi<sup>1</sup>, L. Czornomaz<sup>2</sup>, P. Novák<sup>1</sup>, C. Villevieille<sup>1</sup>, M. El Kazzi<sup>1</sup>

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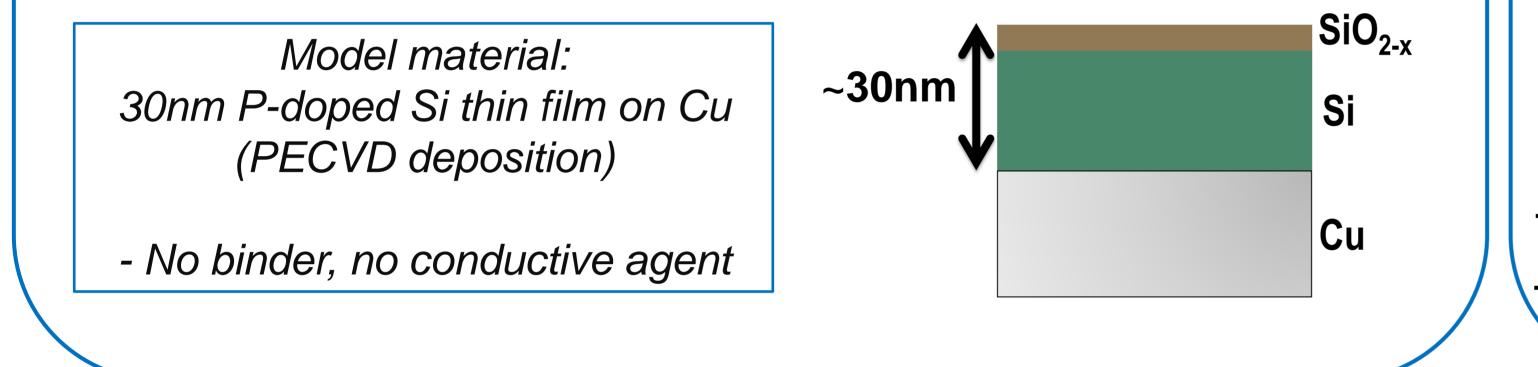
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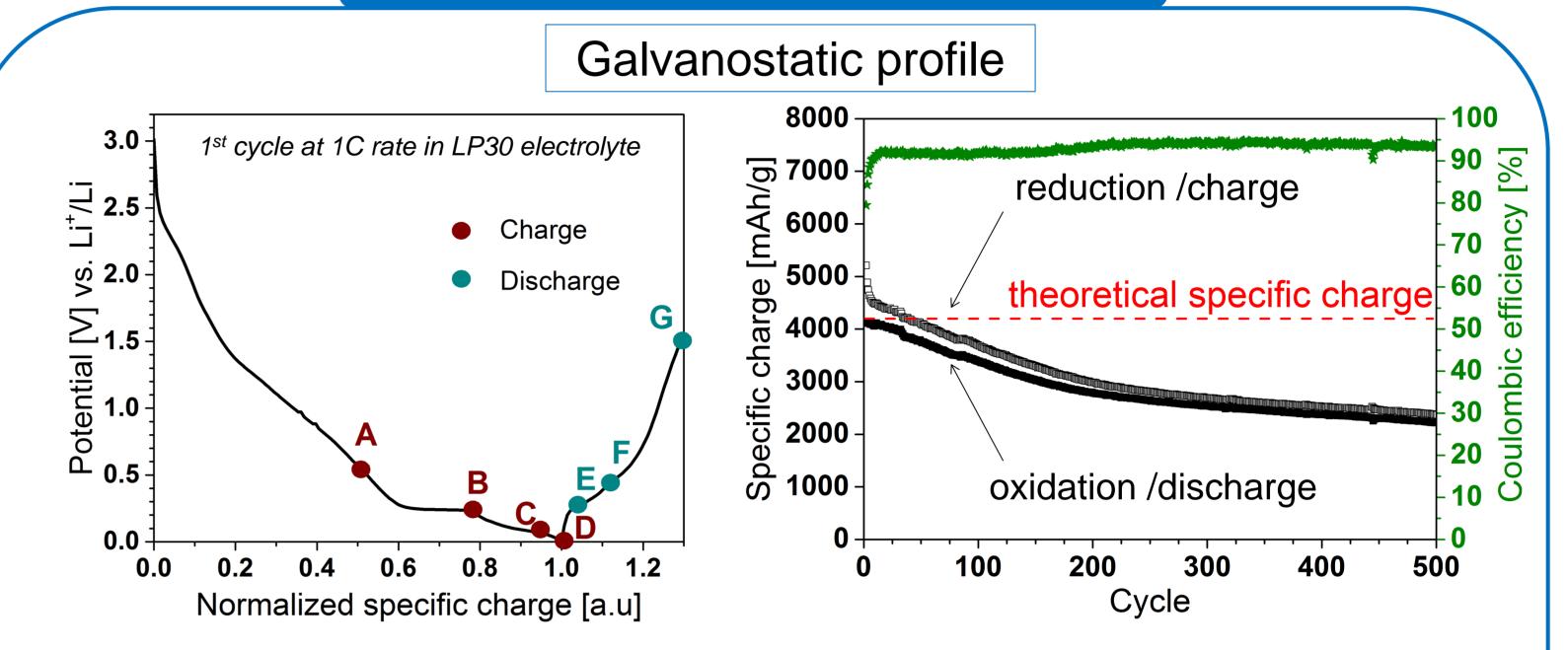
### Motivation

# **Electrochemical performances**

Electrochemical analysis (XPS) surface 30nm of and amorphous phosphorus doped (n-type) Si thin films (used as model material)

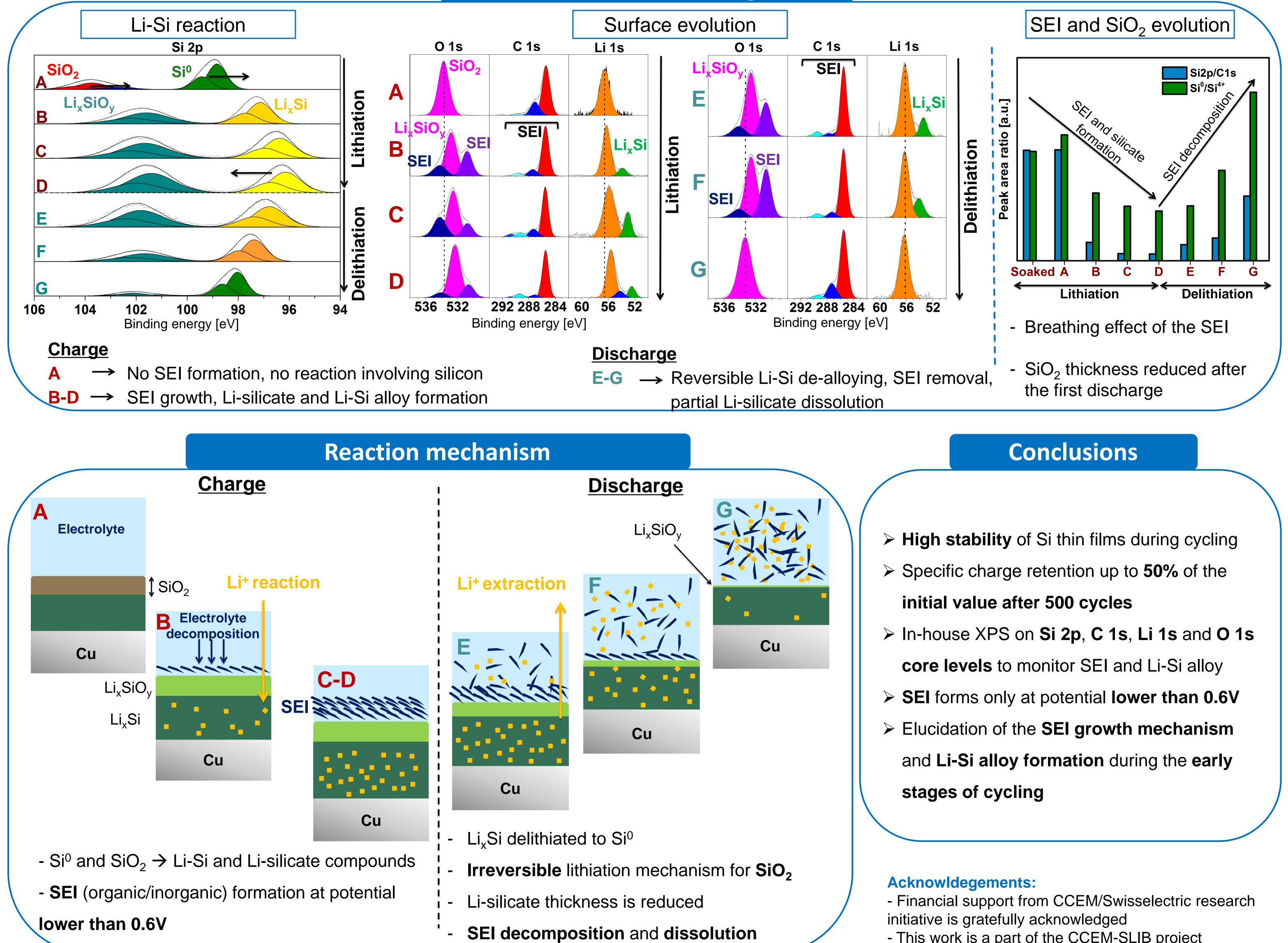
- Understand the properties of the **solid electrolyte interphase** (SEI) growth and Li-Si alloy formation upon lithiation/delithiation





→ 50% specific charge maintained for 500 cycles

### **Post mortem XPS investigation**



- This work is a part of the CCEM-SLIB project